

# **Notice of References Cited**

Application/Control No.

10/702,564

Applicant(s)/Patent Under  
Reexamination  
BISCHEL ET AL.

Examiner

Alessandro V. Amari

Art Unit

2872

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## **U.S. PATENT DOCUMENTS**

*	Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
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B	US-6,408,126	06-2002	Hoekstra, Tsjerk Hans	385/140
C	US-6,377,716	04-2002	Veldhuis et al.	385/143
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K	US-			
L	US-			
M	US-			

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## **NON-PATENT DOCUMENTS**

*	Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
U	Sang-shin Lee et al. "Variable Optical Attenuator based on a cutoff modulator with Tapered Waveguides in polymers" Journal Lightwave Technology, vol. 17, no. 12, (December 1999), pp. 2556-61.
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\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.